

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Shen
#11/9
2-1902

In re the Application of:

Havemann et al.

Examiner: TBD

Serial No: TBD

Art Unit: TBD

Filed: 11/01/01

Docket No.: TI-27506

For: INTEGRATED CIRCUIT HAVING A DOPED POROUS DIELECTRIC AND
METHOD OF MANUFACTURING THE SAME

PRELIMINARY AMENDMENT

November 1, 2001

Assistant Commissioner for Patents

Washington, DC 20231

Dear Sir:

Please amend the above referenced application as follows:

In the Specification:

Page 1, before line 1, insert --This application claims priority under 35 USC §

9' 119(e)(1) of provisional application numbers **60/251,494** filed **12/05/00**.--